

**IN THE CLAIMS:**

Please amend the claims as follows:

1. (Previously Presented) A composition for polishing a metal, the composition comprising:  
a reagent comprising:  
a first moiety for oxidizing the metal; and  
a second moiety for minimizing overetching the metal;  
a stannate salt for stabilizing the composition;  
a corrosion inhibitor; and  
a base.
2. (Original) The composition according to claim 1, wherein the first moiety is reduced to a complexing agent for the metal or oxidized metal.
3. (Currently Amended) The composition according to claim 2, wherein the first moiety comprises a peroxide group selected from the group consisting of a peroxycarboxylic acid group, a peroxycarboxylate group, and combinations thereof, and the resulting complexing agent comprises a carboxylic acid or a carboxylate.
4. (Original) The composition according to claim 1, wherein the second moiety comprises an alkyl group, an alkyl group derivative, an aryl group, an aryl group derivative, or combinations thereof.
5. (Currently Amended) The composition according to claim 4, wherein the second moiety is selected from the group consisting of polyethylene glycol, polyethylene glycol derivatives, benzene, benzene derivatives, and combinations thereof.
6. (Original) The composition according to claim 1, wherein the reagent comprises between about 0.005 wt.% and about 25 wt.% of the composition.

7. (Original) The composition according to claim 1, wherein the stannate salt comprises between about 0.1 ppm and about 20 ppm of the composition.
8. (Currently Amended) The composition according to claim 1, wherein the stannate salt is selected from the group consisting of sodium stannate, potassium stannate, ammonium stannate, and combinations thereof.
9. (Previously Presented) The composition according to claim 1, wherein the base is provided in a sufficient amount to increase the solubility of the resulting complexing agent by forming a salt thereof.
10. (Previously Presented) The composition according to claim 9, wherein the base comprises ammonium hydroxide or potassium hydroxide.
11. (Previously Presented) The composition according to claim 1, wherein the composition has a pH of about 7.
12. (Currently Amended) The composition according to claim 1, wherein the corrosion inhibitor is selected from the group consisting of benzotriazole, imidazole, benzimidazole, benzothiazole, mercaptobenzotriazole, 5-methyl-1-benzotriazole, and combinations thereof.
13. (Previously Presented) The composition according to claim 1, wherein the corrosion inhibitor comprises between about 0.005 wt.% and about 0.05 wt.% of the composition.
14. (Original) The composition according to claim 1, further comprising abrasive particles at a concentration between about 0.1 wt.% and about 30 wt.% of the composition.

15. (Currently Amended) The composition according to claim 3, wherein the peroxycarboxylic acid group is selected from the group consisting of peroxyacetic acid, peroxybenzoic acid, chlorobenzoic acid, peroxyformic acid, polyethylene glycol peroxy acid, and combinations thereof.

16. (Original) The composition according to claim 1, wherein the reagent comprises an amine-peroxy acid.

17-26. (Cancelled)

27. (Currently Amended) A composition for polishing a metal, the composition comprising:

a reagent comprising:

a first moiety comprising a peroxide group selected from the group consisting of a peroxycarboxylic acid group, a peroxycarboxylate group, and combinations thereof; and

a second moiety comprising an alkyl group, an alkyl group derivative, an aryl group, an aryl group derivative, or combinations thereof;

a stannate salt;

a corrosion inhibitor; and

a base.

28. (Original) The composition according to claim 27, wherein the peroxide group reduces to form a complexing agent comprising a carboxylic acid, a carboxylate, or combinations thereof.

29. (Original) The composition according to claim 27, wherein the reagent comprises between about 0.005 wt.% and about 25 wt.% of the composition.

30. (Currently Amended) The composition according to claim 27, wherein the stannate salt comprises between about 0.1 ppm and about 20 ppm of the composition,

and wherein the stannate salt is selected from the group consisting of sodium stannate, potassium stannate, ammonium stannate, and combinations thereof.

31. (Previously Presented) The composition according to claim 27, further comprising abrasive particles.

32. (Original) The composition according to claim 27, wherein the reagent comprises an amine-peroxy acid.

33. (Previously Presented) A composition for polishing a metal, the composition comprising:

a reagent comprising:

a first moiety for oxidizing the metal; and

a second moiety for minimizing overetching the metal;

a stannate salt for stabilizing the composition; and

a base to adjust the pH to about 7.

34. (Currently Amended) The composition according to claim 33, wherein the first moiety is reduced to a complexing agent for the metal or oxidized metal and the base is provided in a sufficient amount to increase the solubility of the ~~resulting~~ complexing agent by forming a salt thereof.

35. (Previously Presented) The composition according to claim 33, wherein the base comprises ammonium hydroxide or potassium hydroxide.

36. (Currently Amended) The composition according to claim 33, wherein the first moiety comprises a peroxide group selected from the group consisting of a peroxycarboxylic acid group, a peroxycarboxylate group, and combinations thereof, the first moiety is reduced to a complexing agent for the metal or oxidized metal, and the resulting complexing agent comprises a carboxylic acid or a carboxylate.

37. (Currently Amended) The composition according to claim 33, wherein wherein the peroxy-carboxylic acid group is selected from the group consisting of peroxyacetic acid, peroxybenzoic acid, chlorobenzoic acid, peroxyformic acid, polyethylene glycol peroxy acid, and combinations thereof, and the second moiety comprises an alkyl group, an alkyl group derivative, an aryl group, an aryl group derivative, or combinations thereof.

38. (Previously Presented) The composition according to claim 33, wherein the reagent comprises between about 0.005 wt.% and about 25 wt.% of the composition and the stannate salt comprises between about 0.1 ppm and about 20 ppm of the composition.

39. (Currently Amended) The composition according to claim 33, wherein the stannate salt is selected from the group consisting of sodium stannate, potassium stannate, ammonium stannate, and combinations thereof.

40. (Currently Amended) The composition according to claim 33, ~~wherein the~~ further comprising a corrosion inhibitor ~~[[is]]~~ selected from the group consisting of benzotriazole, imidazole, benzimidazole, benzothiazole, mercaptobenzotriazole, 5-methyl-1-benzotriazole, and combinations thereof.

41. (Currently Amended) The composition according to claim ~~[[33]]~~ 40, wherein the corrosion inhibitor comprises between about 0.005 wt.% and about 0.05 wt.% of the composition.

42. (Previously Presented) The composition according to claim 33, further comprising abrasive particles at a concentration between about 0.1 wt.% and about 30 wt.% of the composition.